

Ultrahigh-performance humidity-boosted NO₂ sensing using atomically sharp MoS₂ edges

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We developed sub-ppb level NO₂ sensors using multilayer, nanopatterned honeycomb MoS₂ nanomeshes with precise zigzag edges, created through advanced lithography.¹ These nanomeshes, with ribbon thicknesses from hundreds to under ten nanometres, demonstrate uniformity and precision. Our study focused on NO₂ concentrations of 2.5–10 ppb, under the U.S. EPA's threshold.² We found that the NO₂ sensing efficiency of the nanomeshes correlates with the density of hexagonal etching pits, showing optimal response at 200°C due to the exposed zigzag edges and electrical response quality. These sensors exhibit high selectivity for NO₂, with theoretical detection limits between 4 and 400 ppt, and enhanced performance in 70% humidity, even without UV light. This humidity-induced sensitivity boost, also noted for other gases like CO, CH₄, H₂, and C₂H₆, though to a lesser extent than NO₂, suggests a universal mechanism potentially involving H₂O and O₂ competition on the MoS₂ surface under UV light.³

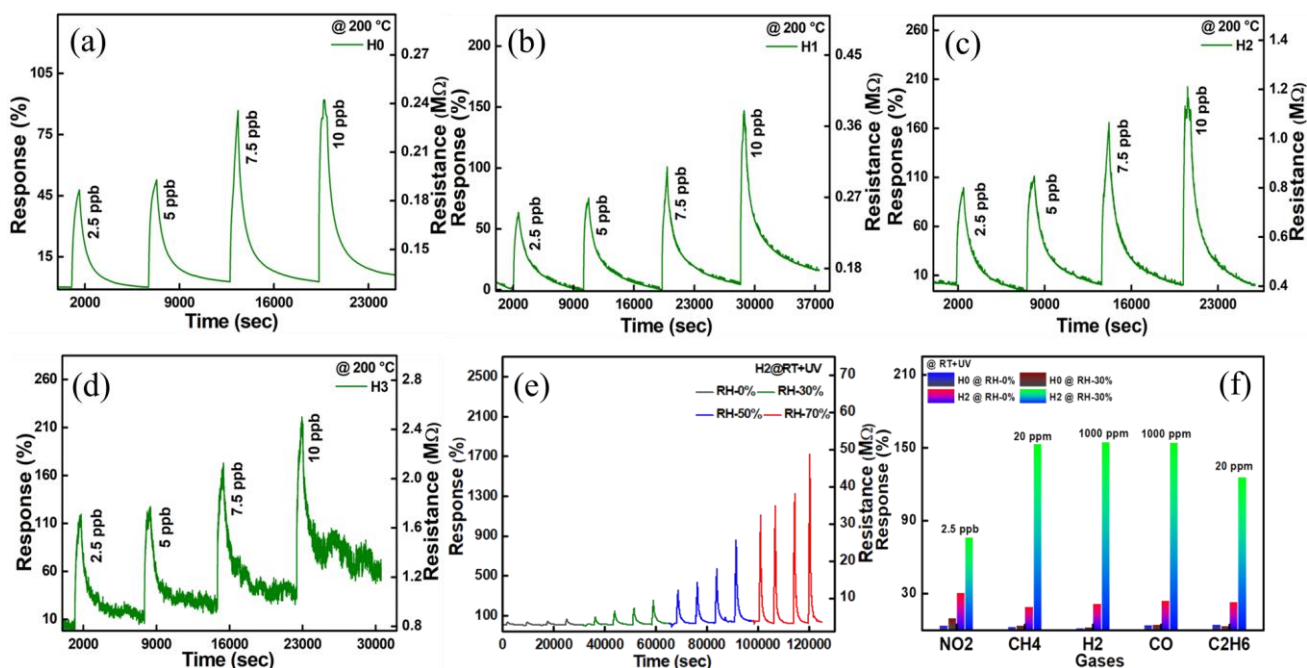


Figure 1: (a-d) The dynamic NO₂ sensing response (2.5-10 ppb) at 200 °C. (e) The broad dynamic NO₂ sensing response (2.5-10 ppb) at RT under UV illumination obtained from the honeycomb nanomesh device. (f) The selectivity profile of nanomesh MoS₂ under 0% and 30% RH for various gases under RT with UV illumination.

References

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